

INFORMATION DISCLOSURE STATEMENT

Atty. Docket No.: 150.0056 0104 Serial No.: Unassigned 12 050639

Applicant(s): Lee et al. Confirmation No.:

Filing Date: Herewith Group: 1765

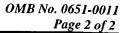
U.S. PATENT DOCUMENTS

Examiner Initial	Copy Enclosed	Document Number	Date	Name	Class	Subclass	Filing Date If
9ú		3,773,577	11/1973	Shibasaki et al.	216	106	
J.J.		4,528,066	07/09/85	Merkling et al.	438	721	
Yú.		4,857,972	10/1989	Williams et al.	257	18	
YC		4,875,973	10/1989	Heikkila et al.	216	107	
S		4,915,781	04/1990	Bohnen et al.	216	107	
di		5,010,032	04/23/91	Tang et al.	438	228	
40		5,047,367	09/10/91	Wei et al.			
\$û		5,086,017	02/04/92	Lu	138	586	
del		5,163,259	11/10/92	Kolar et al.	437	192	
yo		5,198,382	03/30/93	Campbell et al.	437	46	
del		5,302,552	04/12/94	Duchateau et al.	437	200	_
9 e		5,482,895	01/09/96	Hayashi et al.	437	200	
90		5,510,292	04/23/96	Hayashi	438	720	
X0.		5,567,651	10/22/96	Berti et al.	438	303	
90		5,593,924	01/14/97	Apte et al.	437	200	
yv.		5,635,426	06/03/97	Hayashi et al.	438	453	
9/2		5,736,461	04/07/98	Berti et al.	438	651	
State 1		5,880,033	03/09/99	Tsai	438	710	
de		5,919,311	07/1999	Shive et al.	134	1	
do		5,454,901	10/1995	Tsuji	438	753	
40		4,316,765	02/1982	Thiel	438	હ	
40		5,780,363	07/1998	Delehanty et al.	43%	748	
Yû		5,486,266	01/1996	Tsai et al.	438	750	
45		5,858,861	01/1999	Weng et al.	438	750	
90		6,074,960	08/20/1997	Lee et al.	438	749	

EXAMINER Date Considered
4/1/62



^{*}Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



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FOREIGN PATENT DOCUMENTS

Examiner	Сору	Document Number	Date	Country	Class	Subclass	Translation	
Initial	Enclosed						Yes	No
		NONE	•					

OTHER DOCUMENTS (Including Authors, Title, Date, Pertinent Papers, etc.)

,	OTHER DOCUMENTS (Including Authors, Title, Date, Pertinent Papers, etc.)						
Examiner Initial	Copy Enclosed	Document Description					
de		Goto et al., "Optimization of Salicide Processes for sub 0.1-µm CMOS Devices", 1994 Symposium on VLSI Technology Digest of Technical Papers, pgs. 119-120 (1994).					
dy		Ohguro et al., "Nitrogen-doped nickel monosilicide technique for deep submicron CMOS salicide", <i>International Electron Devices Meeting</i> , Washington, D.C., December 10-13, 1995, pgs. 10.3.1-10.3.4.					

EXAMINER	Jo	Date Considered 4/1/02
PE : Table 140 to 1		

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